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10/661,709

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Substitute for form 1449A/PTO **Application Number** Filing Date INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

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09/12/2003 First Named Inventor Blauvelt et al. 2878 Art Unit Suezu Y Ellis **Examiner Name** XPNT22NP 3 Attorney Docket Number

			U.S. PATENT	DOCUMENTS	
Examiner Initials*	Cite No.1	Document Number Number - Kind Code ^{2 (if known)}	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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Examiner		Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Γ.			
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				First Named Inventor	Blauvelt et al.	
317	STATEMENT BY APPLICANT			Art Unit	2878	
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Sheet	2	of	3	Attorney Docket Number	XPNT22NP	

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
		BAZYLENKO ET AL, Fabrication of Light-Turning Mirrors in Buried-Channel silica Waveguides for Monolithic and Hybrid Integration, Journal of Lightwave Technology, 01/1997, Page(s) 148-153, Volume 15, Number 1	
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STATEMENT BY APPLICANT			ANI	Art Unit	2878	
	(Use as many sheets as ne	cessary)	_	Examiner Name	Suezu Y Ellis	
Sheet	3	of	3	Attorney Docket Number	XPNT22NP	

NON PATENT LITERATURE DOCUMENTS					
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